



[TD2] Plasma Sources and Technologies II	
Date / Time	July 26 (Thu.), 2018 / 13:20-15:10
Place	Room D (#115)
Session Chair(s)	Junghoon Joo (Kunsan Nat'l Univ., Korea)

TD2-1 [Invited] 13:20-13:50

The Experimental and Numerical Investigations of Electron Characteristics in 2 MHz and 13.56 MHz Inductively Coupled Hydrogen Plasmas

Fei Gao, Hong Li, De-Qi Wen, and You-Nian Wang
Dalian Univ. of Tech., China

TD2-2 [Invited] 13:50-14:20

Inductively-Coupled Plasma and Laser-Produced Plasma Source Researches at GIST

Hyyong Suk, Keekon Kang, and Sihyeon Lee
GIST, Korea

TD2-3 [Invited] 14:20-14:50

Experimental and Computational Investigations on Striations in Electronegative Capacitively Coupled rf Discharges

Yong-Xin Liu¹, Ihor Korolov², Edmund Schüngel³, Zoltán Donkó⁴, Julian Schulze², and You-Nian Wang¹
¹*Dalian Univ. of Tech., China*, ²*Ruhr-Univ. Bochum, Germany*, ³*Evatec AG, Switzerland*, ⁴*Hungarian Academy of Sciences, Hungary*

TD2-4 14:50-15:10

Modulation of Electron Energy Distribution Functions and Plasma Parameters in a Dual-Frequency Cylindrical Inductively Coupled Plasma Source

Yue Hua, Jian Song, Zeyu Hao, Gailing Zhang, and Chunsheng Ren
Dalian Univ. of Tech., China